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AMENDMENTS TO THE CLAIMS

1-30. (Cancelled)

31. (Withdrawn-Currently Amended) A tarnish-resistant coated object according to elaim 1 claim

40, wherein said object is selected from an ornamental object, a piece of jewelry, an optical object, a

coin, a medal, an electrical object, a kitchen object and a military object.

32. (Withdrawn-Currently Amended) A tarnish-resistant coated object according to elaim 1 claim

40, wherein said object comprises at least one of sterling silver, silver plate and fine silver (100%)

silver).

33-39. (Cancelled)

40. (Withdrawn-Currently Amended) A tarnish-resistant coated object according to claim

1-comprising an object and a silver-tungsten coating on said object, wherein said silver-tungsten

coating is provided by electroless deposition from an aqueous composition comprising:

a soluble source of silver ions;

a soluble source of tungsten ions;

a reducing agent; and

at least one additive polyethylene glycol (PEG); and

wherein said tarnish-resistant coated object has a reflectance of more than 0.6 at 700 nm after a time

period of at least one hour of exposure to heated air.

41. (Currently Amended) A method for providing a tarnish-resistant silver-tungsten coated

object comprising:

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mixing a first aqueous solution comprising a soluble source of silver ions, a soluble

source of tungsten ions and polyethylene glycol (PEG) with a second aqueous solution comprising a

reducing agent so as to provide an active silver tungsten electroless deposition solution; and

immersing an object in said active electroless deposition solution for a time period

sufficient to provide a tarnish-resistant silver tungsten coated object,

wherein said tarnish-resistant silver tungsten coated object is considered to be tarnish-resistant if it

has a reflectance of more than 0.6 at 700 nm after a time period of at least one hour of exposure of

said tarnish-resistant silver tungsten coated object to ambientheated air.

42. (Currently Amended) A method according to claim 41, wherein said first solution comprises

a reducing agentammonium acetate.

43. (Currently Amended) A method according to claim 42 claim 41, wherein said reducing

agent is hydrazine hydrate.

44. (Original) A method according to claim 41, wherein said first solution comprises a chelator.

45. (Currently Amended) A method according to claim 44, wherein said chelator is

ethylenediaminetetraacetic acid (EDTA).

46. (Currently Amended) A method according to claim 41, wherein said-second first solution

comprises a soluble source of silver ions and a soluble source of tungsten ions benzotriazole (BTA).

47. (Original) A method according to claim 41, wherein said object is a metallic object.

48. (Original) A method according to claim 47, wherein said metallic object is a silver object.

49. (Original) A method according to claim 48, wherein said silver object is selected from an

ornamental object, a piece of jewelry, an optical object, a coin, a medal, an electrical object, a

kitchen object and a military object.

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50. (Previously Presented) A method according to claim 48, wherein said silver object comprises at

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least one of sterling silver, silver plate and fine silver (100% silver).

51-52. (Cancelled)

53. (Original) A method according to claim 41, wherein said object is a non-metallic object.

54. (Currently Amended) A method according to claim 53, wherein said non-metallic

object comprises at least one of the following materials: a plastic, a polymer, a ceramic material, a

cellulose-based material, an inorganic material, an organic material and a fabric.

55-63. (Cancelled)

64. (Withdrawn-Currently Amended) An electroless plating composition comprising an aqueous

solution for electrolessly plating a surface, comprising:

a soluble source of silver ions;

a soluble source of tungsten ions;

a reducing agent;

at least one additive; and

a polymer adapted to induce filling of at least one of:

a substantially vertical trench of more than 300 nm depth: and

a substantially horizontal gap of more than 200 nm width;

on said surface polyethylene glycol; and

wherein said plating composition is adapted to electrolessly deposit a corrosion-free

conformal tarnish-resistant layer of silver tungsten on said surface, wherein said layer is from about

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0.05 to around 10 microns thick has a reflectance of more than 0.6 at 700 nm after a time period of

at least one hour of exposure of said tarnish-resistant silver tungsten coated object to heated air.

65-115. (Cancelled)

116. (Withdrawn-Currently Amended) An electroless plating composition for preventing

discoloration of a metallic object comprising an aqueous electroless plating solution, comprising:

a soluble source of silver ions;

a soluble source of tungsten ions;

a reducing agent; and

at least one additive polyethylene glycol (PEG); and

wherein said plating composition is adapted to electrolessly deposit a layer of silver-

tungsten on said metallic object so as to provide a silver-tungsten plated metallic object such that

said silver-tungsten plated metallic object has less than a 5% increase in light absorbance in a range

of incident light at 400-700 nm after exposure to ambient air for a time period of at least one week a

reflectance of more than 0.6 at 700 nm after a time period of at least one hour of exposure of said

tarnish-resistant silver tungsten coated object to heated air.

117-129. (Cancelled)

130. (Currently Amended) A method for providing a silver ternary metal layer on a surface,

comprising:

electrolessly plating said surface in an electroless plating composition for a sufficient

time to plate said surface with at-least-one-of-a silver tungsten molybdenum layer and a silver

tungsten rhenium layer.

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131. (Cancelled)

132. (Withdrawn-Currently Amended) An electroless plating composition, comprising:

a soluble source of silver ions;

a soluble source of tungsten ions;

at least one of a soluble source of molybdenum and a soluble source of rhenium;

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a reducing agent; and

at least one-additive polyethylene glycol.

133. (Cancelled)